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LABORATORY GROWN DIAMOND REPORT

July 25, 2026

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG815699974

Report verification at [igi.org](#)

PROPORTIONS

Sample Image Used

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

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LABORATORY GROWN DIAMOND

EMERALD CUT

11.88 X 7.91 X 5.41 MM

5.10 CARATS

E

VVS 2

EXCELLENT

EXCELLENT

NONE

IGI LG815699974

EXCELLENT

EXCELLENT

NONE

IGI LG815699974



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IGI

July 25, 2026

IGI Report No LG815699974

EMERALD CUT

11.88 X 7.91 X 5.41 MM

5.10 CARATS

E

VVS 2

68.4%

64%

Slightly Thick

Long

EXCELLENT

EXCELLENT

NONE

IGI LG815699974

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